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8/20/01
TJK/180/L.W.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of Hong-Sik BYUN et al.) PLASMA PROCESSING APPARATUS
)
Korean Appln. No. 2000-30050)
)
Korean Filing Date: June 1, 2000)

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

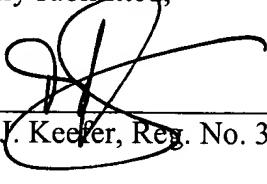
Please amend the subject application as follows:

--CROSS REFERENCE TO RELATED APPLICATION

A'
This application claims the priority of Korean patent application Serial No. 2000-30050
filed on June 1, 2000.-

Date: 5/31/01
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Respectfully submitted,

By: 
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CERTIFICATE OF EXPEDITED

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I hereby certify that this paper or set is being transmitted via
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Addressee on the date indicated above and is addressed to
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Melissa Parada